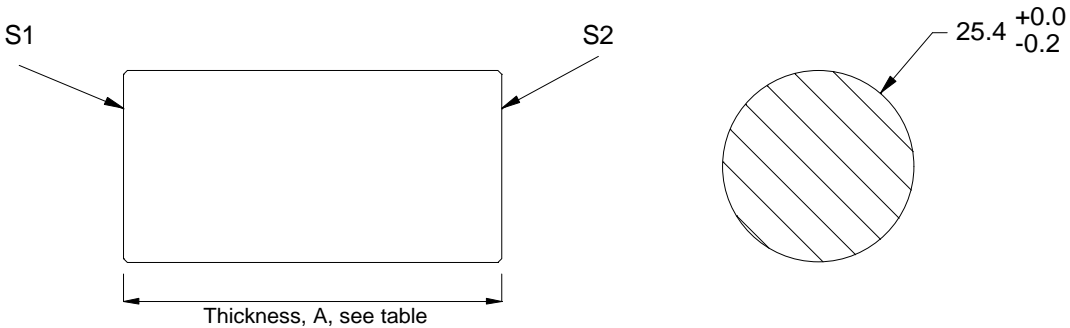


REVISIONS			
REV	REVISED PER	Date	Approved
A	first release	2006 Jun 21	IJM
B	CN 1260	Nov 20, 2006	JHH



Part Number	Thickness, A	Tolerance
OP-2638-X	X	the greater of $\pm 1\%$ of thickness or $\pm 0.001\text{mm}$

Notes:

1. S1 and S2 flat to $\lambda/10$ at 633 nm, parallel within 5 arc seconds.
2. S1 and S2, scratch dig 80-50, barrel fine grind, edges chamfered approximately 0.7 mm face width.
3. Single crystal silicon.
4. Clear aperture 80%.
5. Uncoated.

Silicon Etalon 25.4 mm
LightMachinery OP-2638-X

dimensions mm	material single crystal Si
Tolerances (unless otherwise noted) X ± 0.5 A $\pm 1^\circ$ X.X ± 0.1 A.A $\pm 0.1^\circ$ X.XX ± 0.025	
Drawing Template QT-730-002-E	
Scale 1:1 Third angle projection	

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